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### Process chamber manifold

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### Description

(1) FIG. 1 is a top, front, left side isometric view of a process chamber manifold, showing our new design.

- (2) FIG. 2 is a bottom, rear, right side isometric view thereof.
- (3) FIG. 3 is a left side elevation view thereof.
- (4) FIG. 4 is a right side elevation view thereof.
- (5) FIG. 5 is a front elevation view thereof.
- (6) FIG. 6 is a rear elevation view thereof.
- (7) FIG. 7 is a top plan view thereof.
- (8) FIG. 8 is a bottom plan view thereof.
- (9) FIG. 9 is a cross-sectional view taken along line 9-9 in FIG. 7; and,
- (10) FIG. 10 is a cross-sectional view taken along line 10-10 in FIG. 7.

## Claims

The ornamental design for a process chamber manifold, as shown and described.

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